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## CORRECTION

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## Correction: Influence of Cu doping on the visible-light-induced photocatalytic activity of InVO<sub>4</sub>

Natda Wetchakun, (10 \*\* Pimonrat Wanwaen, a Sukon Phanichphant (10 b) and Khatcharin Wetchakun (10 c)

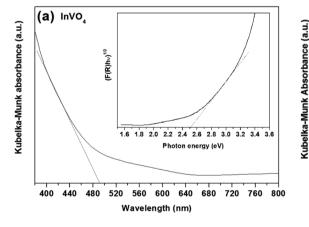
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Correction for 'Influence of Cu doping on the visible-light-induced photocatalytic activity of InVO<sub>4</sub>' by Natda Wetchakun *et al.*, *RSC Adv.*, 2017, 7, 13911–13918, DOI: 10.1039/C6RA27138C.

The authors regret errors in Fig. 4, 7, and 9 in the previously published article. The corrections for the errors in the article are described as follows:

- (1) The diffuse reflectance spectra of pure InVO<sub>4</sub> and 1.0 mol% Cu-doped InVO<sub>4</sub> are shown in Fig. 4. The absorption margin of 1.0 mol% Cu-doped InVO<sub>4</sub> was shifted to a longer wavelength, indicating a decrease in the band gap with respect to pure InVO<sub>4</sub>. The absorption margins of the pure InVO<sub>4</sub> and 1.0 mol% Cu-doped InVO<sub>4</sub> samples were 505 nm and 510 nm, corresponding to band gaps of 2.51 eV and 2.45 eV, respectively (Fig. 4a and b).
- (2) The band edge positions of the conduction band (CB) and the valence band (VB) of InVO<sub>4</sub> can be calculated by the following equation:  $E_{CB}^0 = \chi E^C 0.5E_g$ , where  $\chi$  is the electronegativity of the semiconductor,  $E^C$  is the energy of free electrons on the hydrogen scale of 4.5 eV,  $E_g$  is the band gap of InVO<sub>4</sub>, and the  $\chi$  value of InVO<sub>4</sub> is 5.74 eV. The  $E_g$  value of InVO<sub>4</sub> evaluated from the UV-vis DRS analysis was about 2.51 eV. The valence band energy ( $E_{VB}$ ) can be calculated by the following equation:  $E_{VB}^0 = E_{CB}^0 + E_{CB}^0 +$



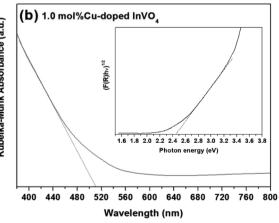


Fig. 4 Kubelka-Munk absorbance spectra and band gaps (insets) of the pure  $InVO_4$  (a) and 1.0 mol% Cu-doped  $InVO_4$  (b) samples.

<sup>&</sup>quot;Department of Physics and Materials Science, Faculty of Science, Chiang Mai University, Chiang Mai 50200, Thailand. E-mail: natda\_we@yahoo.com

<sup>&</sup>lt;sup>b</sup>Materials Science Research Center, Faculty of Science, Chiang Mai University, Chiang Mai 50200, Thailand

Program of Physics, Faculty of Science, Ubon Ratchathani Rajabhat University, Ubon Ratchathani 34000, Thailand

Fig. 7 Schematic of the charge migration and separation on Cu-doped InVO<sub>4</sub>

radical ion (O<sub>2</sub>  $\dot{}$  ). In addition, the VB of InVO<sub>4</sub> (2.49 eV) is higher than the standard redox potential,  $E^0$ (OH $^-$ /OH $^+$ ) = 1.99 V  $\nu$ s. NHE at pH 7. This indicates that the photogenerated holes in the valence band of InVO<sub>4</sub> can oxidize the hydroxyl ion (OH $^-$ ) or water (H<sub>2</sub>O) to form the hydroxyl radical (OH $^+$ ).

(3) Due to the contradiction between the scavenging test and the proposed photocatalytic mechanism, Fig. 9 was removed from the original article.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

## References

Correction

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